

	Type	L #	Hits	Search Text	DBs	Comments
1	BRS	L1	147613	438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
2	BRS	L2	560	1 and (remov\$3 or clean\$3 or etch\$3) near ((photoresist or resist) and residue)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
3	BRS	L3	323	2 and (trench or void or opening)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
4	BRS	L4	248	3 and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
5	BRS	L5	107	4 and wet near (etch\$3 or chemistry)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
6	BRS	L6	45	5 and anneal\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
7	BRS	L7	10	(smith-patricia or eissa-mona-m).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
8	BRS	L8	4831	((remov\$3 or clean\$3 or etch\$3) near ((photoresist or resist) or residue)).ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
9	BRS	L9	735	8 and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
10	BRS	L10	142	9 and ((hydrogen or NH?) and oxygen)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
11	BRS	L11	7	10 and CF?	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
12	BRS	L12	46	9 and wet near (etch\$3 or chemistry)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
13	BRS	L13	3	12 and (hydrofluoric and (organic or citric or acetic or oxalic)) near acid	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
14	BRS	L14	1371	(remov\$3 or clean\$3 or etch\$3) near ((photoresist or resist) and residue)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
15	BRS	L15	896	14 and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
16	BRS	L16	227	15 and ((hydrogen or NH?) and oxygen and (CF? or fluorine))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
17	BRS	L17	226	15 and ((hydrogen or NH?) and oxygen and (CF? or fluorine) and (N? or nitrogen))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	
18	BRS	L18	24	17 and (hydrofluoric and (organic or citric or acetic or oxalic)) near acid	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	